

CORRECTION

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Correction: Integrated 4-terminal single-contact nanoelectromechanical relays implemented in a silicon-on-insulator foundry process

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Correction for 'Integrated 4-terminal single-contact nanoelectromechanical relays implemented in a silicon-on-insulator foundry process' by Yingying Li et al., *Nanoscale*, 2023, <https://doi.org/10.1039/d3nr03429a>.

The authors regret the omission of one corresponding author, Dinesh Pamunuwa, from the original manuscript. The corrected list of authors and affiliations for this paper is as shown above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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